Photovoltaic cell and module physics and technology

Vitezslav Benda, Prof Czech Technical University in Prague <u>benda@fel.cvut.cz</u> www.fel.cvut.cz

Outlines

- Photovoltaic Effect
- Photovoltaic cell structure and characteristics
- Photovoltaic cell construction and technology
- PV modules construction and technology
- Summary

Solar energy







Photovoltaics

Direct transformation energy of solar irradiation into electricity

1. Light absorption in materials and excess carrier generation

Photon energy $hv = hc/\lambda$ (h is the Planck constant) photon momentum ≈ 0

Light is absorbed in the material.

 $\Phi(x) \text{ is the light intensity} \qquad \Phi(x) = \Phi_0 \exp(-\alpha x) = \Phi_0 \exp\left(-\frac{x}{x_L}\right)$ $\alpha = \alpha(\lambda) \text{ is the absorption coefficient}$ $x_L = \frac{1}{\alpha} \text{ is the so-called absorption length} \qquad \int_0^{x_L} \Phi(x) dx = 0.68 \int_0^{\infty} \Phi(x) dx$

Absorption is due to interactions with material particles (electrons and nucleus). If particle energy before interaction was W_1 , after photon absorption is $W_1 + hv$

- interactions with the lattice -results in an increase of temperature
- interactions with free electrons results also in temperature increase
- interactions with bonded electrons- the incident light may generate some excess carriers (electron/hole pairs)

At interaction with photons of energy $h_V \ge W_g$ electron are generated and carrier generation increases

electron-hole pairs

 $R = \left(\frac{d\Delta n}{dt}\right) = -\frac{\Delta n}{\tau}$



Excess carriers recombine with the recombination rate τ is so called carrier lifetime

In dynamic equilibrium $\Delta n = \Delta p = \tau G$

Efficiency of excess carrier generation by solar energy depens on the semiconductor band gap



To obtain a potential difference that may be used as a source of electrical energy, an inhomogeneous structure with internal electric field is necessary.

Suitable structures with built-in electric field:

• PN junction

• heterojunction (contact of different materials).

• PIN structures



Principles of solar cell function



In the illuminated area generated excess carriers diffuse towards the PN junction. The density J_{PV} is created by carriers collected by the built-in electric field region

$$J_{PV}(\lambda) = q \int_{0}^{H} G(\lambda; x) dx - q \int_{0}^{H} \frac{\Delta n}{\tau} dx - J_{sr}(0) - J_{sr}(H)$$

$$J_{sr} \text{ is surface recombination}$$

Total generated current density

$$J_{PV} = \int J_{PV}(\lambda) d\lambda$$

Illuminated PN junction:Asupperposition of photo-generatedcurrent and PN junction (dark)I-V characteristic



Solar cell I-V chacteristic and its importan points



Important solar cell electrical parameters



All parameters V_{OC} , I_{SC} , V_{mp} , I_{mp} , FF and η are usually given for standard testing conditions (STC):

- spectrum AM 1.5
- radiation power 1000 W/m²
- cell temperature 25°C.

Modelling I-V characteristics of a solar cell



$$I = A_{ill}J_{PV} - AJ_{01}\left[\exp\left(q\frac{V+R_sI}{\varsigma_1kT}\right) - 1\right] - AJ_{02}\left[\exp\left(q\frac{V+R_sI}{\varsigma_2kT}\right) - 1\right] - \frac{V+R_sI}{R_p}$$

Influence of temperature

For a high R_n

a high R_p
$$V_{OC} \approx \frac{kT}{q} \ln \frac{I_{PV}}{I_{01}}$$

 $I_{01} \sim n_i^2 = BT^3 \exp\left(\frac{-W_g}{kT}\right)$

Consequently

$$\frac{\partial V_{OC}}{\partial T} < 0$$

For silicon cells the decrease of V_{OC} is about 0.4%/K

Both fill factor and efficiency decrease with temperature

$$\frac{\partial FF}{\partial T} < 0 \qquad \qquad \frac{\partial \eta}{\partial T} < 0$$

At silicon cells
$$\frac{1}{\eta} \frac{\partial \eta}{\partial T} \approx 0.5\% K^{-1}$$



0.087

CuInSe₂

-6.52

The resistances R_s and R_p influences the cell efficiency

At a constant irradiance







Optimising cell thickness and PN junction depth

The photo-current density J_{PV} consists from carriers collected by the electric field in the space charge region of the PN junction, i.e. from carriers generated in a distance of about diffusion length from the PN junction.

The PN junction depth x_j should be less than 0.5 µm (0.2 µm is desirable).

To decrease recombination, defects should be passivated



Optical losses

Surface texturing

If the surface has a pyramidal structure it is possible to decrease reflection on about one third of that on a plane surface



Wavelength (nm)

Both principles (surface texturing and antireflection coating) can be combined to minimise losses by surface reflection

Antireflection coating

Electrical losses

Series resistance R_s influences strongly solar cells efficiency

Series resistance R_s consists of:

•R₁ – contact metal-semiconductor on the back surface

- •R₂ base semiconductor material
- •R₃ lateral emitter resistance between two contact grid fingers
- •R₄ contact metal-semiconductor on the grid fingers
- • R_5 resistance of the grid finger
- •R₆ resistance of the collector bus



$$R_2 = \rho_{Si} H / A$$

$$R_3 \sim \frac{\rho_N d}{x_j}$$



$$R_6 \sim \frac{\rho_M l_B}{h b_B}$$



Preparing semicondutor silicon



PV cells and modules from crystalline silicon (c-Si)

PV cells are realised from crystalline silicon wafers of thickness 0,15 - 0,25 mm and sides of 100 - 200 mm



Standard mass production (c-Si cells)

- starting P-type wafers
- chemical surface texturing
- phosphorous diffusion
- SiN(H) antireflection surface coating and passivation
- contact grid realised by the screen print technique
- contact firing
- edge grinding

mono-crystalline $\eta \approx 17\%$

• cell measuring and sorting

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multi-crystalline $\eta \approx 16\%$

The technology limit is $\eta \approx 19\%$

Increasing cell efficiency



A single solar cell.....~0.5 V, about 30 mA/cm²

For practical use it is necessary connect cells in series to obtain a source of higher voltage and in parallel to obtain a higher current



Cell connection in parallel



Cells in series..... the same current flows through all cells voltage does sums





PV c-Si module technology



Bypass diodes



Module parameters

- open circuit voltage V_{OC} ,
- short circuit current I_{SC}
- maximum output power $V_{mp}I_{mp}$

• fill factor
$$FF = \frac{V_{mp}I_{mp}}{V_{OC}I_{SC}}$$

• efficiency
$$\eta = \frac{V_{mp}I_{mp}}{P_{in}} = \frac{V_{OC}I_{SC}FF}{P_{in}}$$

STC (25°C, 1kW/m², AM 1,5)

Real operating temperature

$$T_c = T_a + r_{thca}G_{ab}$$

$$r_{\text{thca}} = \frac{r_{\text{thcaf}} r_{\text{thcab}}}{r_{\text{thcaf}} + r_{\text{thcab}}} \qquad r_{thcab} = \frac{d_b}{\lambda_b} + \frac{1}{h_b} \qquad r_{thcaf} = \frac{d_f}{\lambda_f} + \frac{1}{h_f}$$

NOCT (Nominal Operating Conditions Temperature) Ambient temperature 20°C, 800 W/m², wind 1 m/s

Thin film solar cells

Market share:

1.5%

5.7%

4.7%

Amorphous silicon solar cells

TCO: SnO₂ ITO (indium-tin oxide) ZnO

Light trapping

Plasma enhanced CVD (PECVD)

- RF electrode and substrate create the capacitor structure.
- In this space the plasma and incorporated deposition of material on substrate takes place

deposition of silicon nitride $3SiH_4 + 3NH_3 \rightarrow Si_3N_4 + 12H_2$ deposition polysilicon layers $SiH_4 \rightarrow Si + 2H_2$. The deposited layer structure depends on the gas composition and substrate temperature

150 – 350°C

dilution ratio rH = ([H2] + [SiH4])/[SiH4].

rH < 30, amorphous silicon growth rH > 45, crystalline layers are formed

Thin film solar cell technology

Amorphous (microcrystalline) silicon solar cells

Tandem cells

Thin-film modules on glass substrates

Back surface is laminated with EVA and suitable covering sheet (glass, tedlar)

Market share development

PV module cost development

Reduction of silicon cost 2008..... 500 USD/kg 2010.....55 USD/kg 2012..... 22 USD/kg

Reduction of C-Si module cost

Thin-film modules are not cheaper than modules from crystalline silicon (yet)